

EXHIBIT I

16-1831

The Department of State refers the Embassy of the People's Republic of China to its diplomatic note No. CE100/16, dated June 10, 2016, which provides information about Rilin Company construction workers seeking acceptance of accreditation from the Department.

The Department wishes to inform the Embassy that the Department is unable to accept the accreditation to the Consulate General in New York of the 59 workers for whom notifications of appointment were submitted in March (see enclosure). Except for WANG, Landong the status of these workers will cease in 10 calendar days from the date of this note.

Additionally, after the Department's acceptance of their accreditation for duties at the Chinese Embassy, YU, Bin and YU, Wangui departed the United States on October 7, 2008, and October 29, 2008, respectively, and the privileges and immunities of each employee ceased as of his respective departure date. After the Department's acceptance of his accreditation for duties at the Chinese Embassy, WANG, Lizhi departed the United States on January 8, 2009, and his privileges and immunities ceased as of his departure date.

DIPLOMATIC NOTE

Additionally, after the Department's initial acceptance of ZHANG, Ming at the Chinese Permanent Mission to the United Nations for purposes of privileges and immunities, ZHANG, Ming departed the United States on December 26, 2011, and his privileges and immunities ceased as of his departure date.

The Department does not consider the four workers named above as properly accredited at this time.

After the Department's acceptance of his accreditation for duties at the Chinese Embassy, WANG, Landong according to the information in Note No. CE100/16, has instead lived in New York and New Jersey, and worked in New York, since June 2007. Consequently, as his functions at the Chinese Embassy ended when he left the Washington, D.C., area in response to the Embassy's Diplomatic Note numbered CE043/16 of March 22, 2016, the Department informs the Embassy that it is unable to accept the accreditation of WANG, Landong and any privileges and immunities to which he may have been entitled will cease at noon November 11, 2016.

Enclosure:

As stated.



Department of State,

Washington, November 9, 2016

Appendix A

Deng, Lixiang

Deng, Wei

Fang, Yi

Gao, Fuyou

Gao, Xiaofeng

Gu, Zuqiang

Hu, Dedong

Ji, Hongtao

Ji, Yan

Kong, Fanwen

Kou, Yanqing

Lan, Xingheng

Li, Shouyan

Li, Zhili

Liang, Fenglin

Liang, Yongguo

Liang, Zhizhong

Lu, Danchen

Lu, Shibin

Lu, Xiaohui

Ma, Jun

Ma, Runzhong

Mou, Zuopeng

Ren, Changhe

Shi, Shouming

Shi, Shanying

Song, Zhiqiang

Sui, Chundong

Sui, Fukuan

Sun, Deyi

Sun, Kan

Tang, Dehuai

Teng, Xueliang

Tian, Liangyong

Wang, Aijun

Wang, Changlin

Wang, Landong

Wang, Lizhi

Wang, Shengwei

Wang, Wenfu

Wang, Xingshi

Wang, Yuliang

Wu, Wenrun

Wu, Yehan

Xia, Yunpeng

Yu, Bin

Yu, Wangui

Yuan, Tongwu

Zhang, Bo

Zhang, Chunjun

Zhang, Guohe

Zhang, Guoyou

Zhang, Ming

Zhang, Ruijun

Zhang, Shuyan

Zhang, Xulong

Zhao, Jun (DOB April 1, 1973)

Zheng, Guoji

Zheng, Weiguo

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Hu, Dedong
Ji, Hongtao
Ji, Yan
Kong, Fanwen
Kou, Yanqing
Lan, Xingheng
Li, Shouyan
Li, Zhili
Liang, Fenglin
Liang, Yongguo
Liang, Zhizhong
Lu, Danchen
Lu, Shibin
Lu, Xiaohui
Ma, Jun
Ma, Runzhong
Mou, Zuopeng
Ren, Changhe
Shi, Shouming
Shi, Shanying
Song, Zhiqiang
Sui, Chundong
Sui, Fukuan
Sun, Deyi

Sun, Kan
Tang, Dehuai
Teng, Xueliang
Tian, Liangyong
Wang, Aijun
Wang, Changlin
Wang, Landong
Wang, Lizhi
Wang, Shengwei
Wang, Wenfu
Wang, Xingshi
Wang, Yuliang
Wu, Wenrun
Wu, Yehan
Xia, Yunpeng
Yu, Bin
Yu, Wangui
Yuan, Tongwu
Zhang, Bo
Zhang, Chunjun
Zhang, Guohe
Zhang, Guoyou
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